

2100 Pennsylvania Avenue, NW Washington, DC 20037-3213 T 202.293.7060 F 202.293.7860

www.sughrue.com

February 14, 2002

BOX PATENT APPLICATION Commissioner for Patents Washington, D.C. 20231

Re:

Application of Tsutomu SHOKI and Morio HOSOYA

REFLECTION TYPE MASK BLANK FOR EUV EXPOSURE AND REFLECTION TYPE MASK FOR EUV EXPOSURE AS WELL AS METHOD OF PRODUCING THE

MASK

**Assignee: HOYA CORPORATION** 

Our Ref. Q68554

Dear Sir:

Attached hereto is the application identified above comprising twenty-nine (29) sheets of the specification, including the claims and abstract, three (3) sheets of drawings, executed Assignment and PTO 1595 form, and executed Declaration and Power of Attorney.

The Government filing fee is calculated as follows:

Total claims	8 - 20	= x	\$18.00 =	\$.00
Independent claims	2 - 3	= x	\$84.00 =	\$.00
Base Fee		<del></del>		\$740.00
Multiple Dependent Claim Fee				\$280.00
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TOTAL FILING FEE\$1020.00Recordation of Assignment\$40.00TOTAL FEE\$1060.00

Checks for the statutory filing fee of \$1020.00 and Assignment recordation fee of \$40.00 are attached. You are also directed and authorized to charge or credit any difference or overpayment to Deposit Account No. 19-4880. The Commissioner is hereby authorized to charge any fees under 37 C.F.R. §§ 1.16 and 1.17 and any petitions for extension of time under 37 C.F.R. § 1.136 which may be required during the entire pendency of the application to Deposit Account No. 19-4880. A duplicate copy of this transmittal letter is attached.

Priority is claimed from:

Country

Application No

Filing Date

Japan

37034/2001

February 14, 2001

The priority document will be filed at a later date.

Respectfully submitted, SUGHRUE MION, PLLC

Attorneys for Applicant

p.,

Alan J. Kasper

Registration No. 25,426

AJK/amt